

XIII ème colloque Louis Néel

# Ultrathin epitaxial cobalt films on graphene: perpendicular magnetic anisotropy

C. Vo-Van<sup>1</sup>, Z. Kassir-Bodon<sup>1</sup>, H. Yang<sup>2</sup>, J. Coraux<sup>1</sup>, J. Vogel<sup>1</sup>,  
S. Pizzini<sup>1</sup>, P. Bayle-Guillemaud<sup>3</sup>, M. Chshiev<sup>2</sup>, L. Ranno<sup>1</sup>, V.  
Santonacci<sup>1</sup>, P. David<sup>1</sup>, V. Salvador<sup>3</sup>, and O. Fruchart<sup>1</sup>.

*<sup>1</sup>Institut Néel, CNRS & UJF*

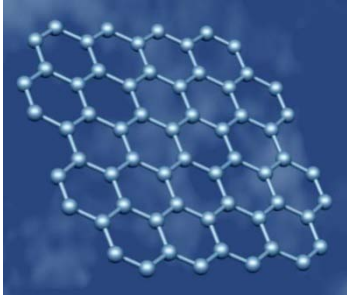
*<sup>2</sup>SPINTEC, CEA/CNRS/UJF/G-INP, INAC*

*<sup>3</sup>CEA-Grenoble, INAC/SP2M/LEMMA*

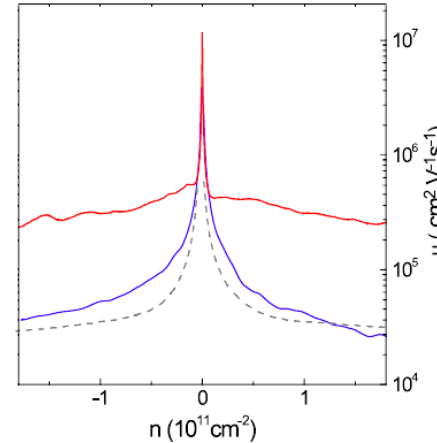
- Growth & structure of ultrathin Co films on graphene
- Perpendicular magnetic anisotropy
- Low coercive field
- Weak domain wall pinning

Chi Vo-Van, Zoukaa Kassir-Bodon, Hongxin Yang, Johann Coraux, Jan Vogel, Stefania Pizzini, Pascale Bayle-Guillemaud, Mairbek Chshiev, Laurent Ranno, Valérie Santonacci, Philippe David, Violaine Salvador, and Olivier Fruchart, *submitted*.

# Graphene in spintronics

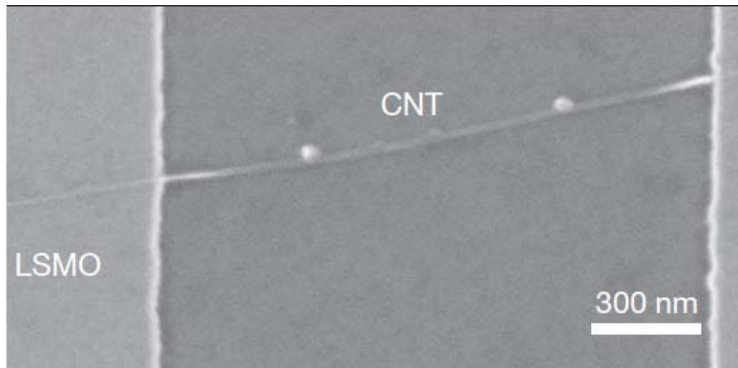


- Weak spin-orbit coupling
  - Low hyperfine interaction
  - High electron mobility
- ➔ Long-range spin transport

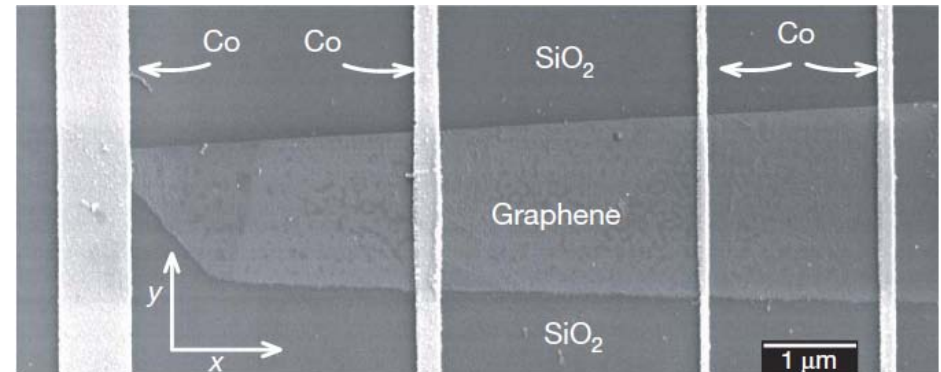


High  $\mu$  at 300K and noticeable charge doping

K. Bolotin, et al., Sol. State Comm. **146**, 351 (2008).



L. E. Hueso, et al., Nature **445**, 410 (2007).



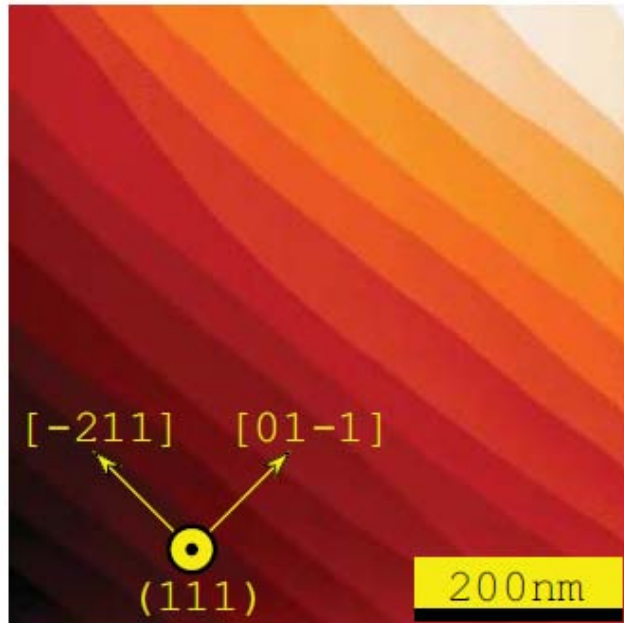
N. Tombros, et al., Nature **448**, 571 (2007).

Graphene ➔ integrability and patterning  
(on-wafer sample)

# High quality of Ir (111) on sapphire

Pulsed-Laser Deposition under UHV  
Deposition: 430°C; Annealing: 850°C

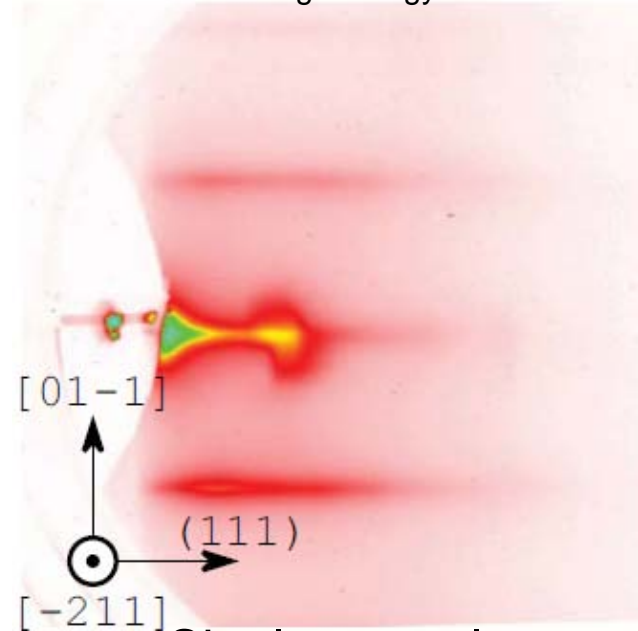
STM



Thickness: 9nm  
Atomic steps

C. Vo-Van et al., in preparation

RHEED: Reflection high energy electron diffraction

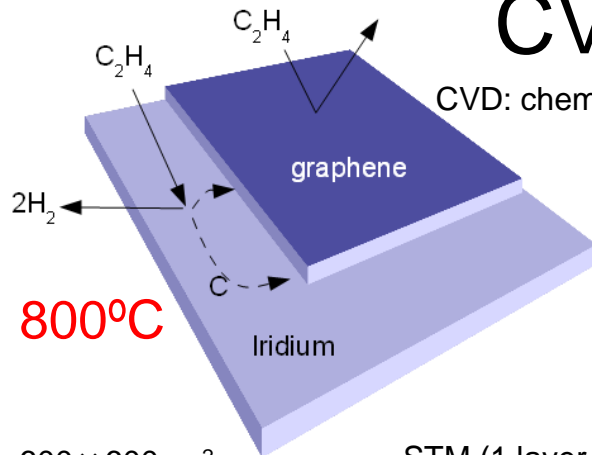


Single crystal

Ir (111)-9nm

Sapphire (0001)

# CVD of Graphene on Ir



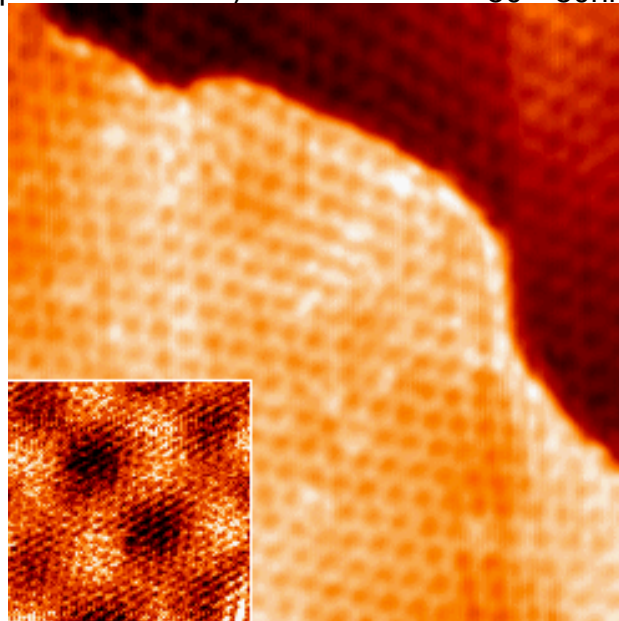
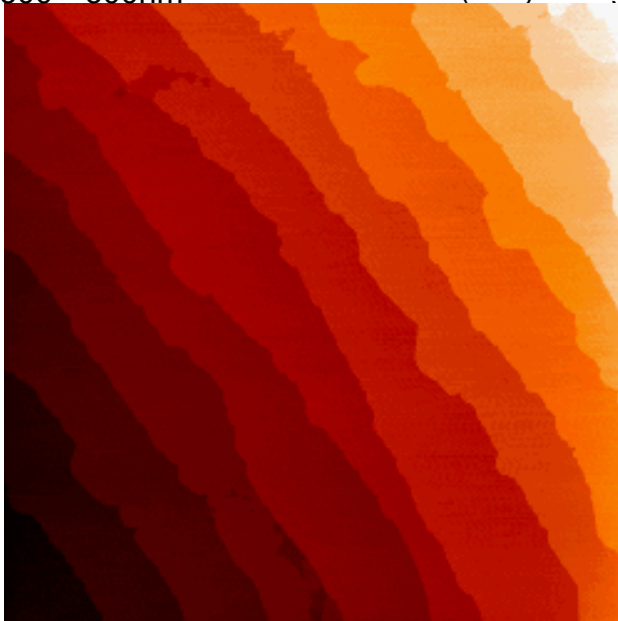
- Single layer (self-limiting)
- ~ full coverage
- Comparable to results on single crystal

J. Coraux, et al., Nano Lett. **8**(2), 565 (2008).

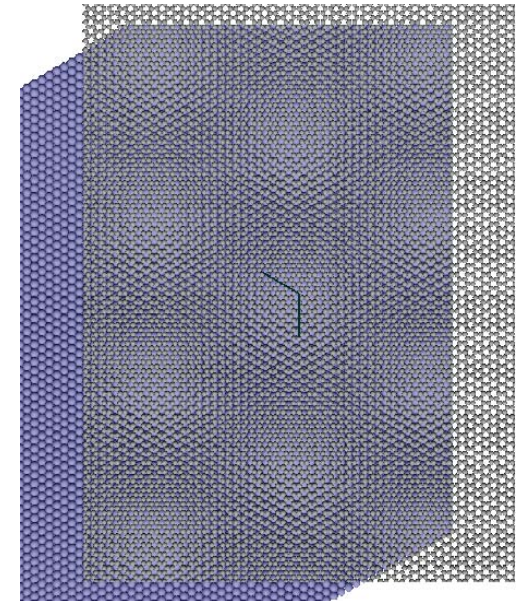
$600 \times 600 \text{ nm}^2$

STM (1 layer of graphene on Ir-9nm)

$50 \times 50 \text{ nm}^2$



$5 \times 5 \text{ nm}^2$

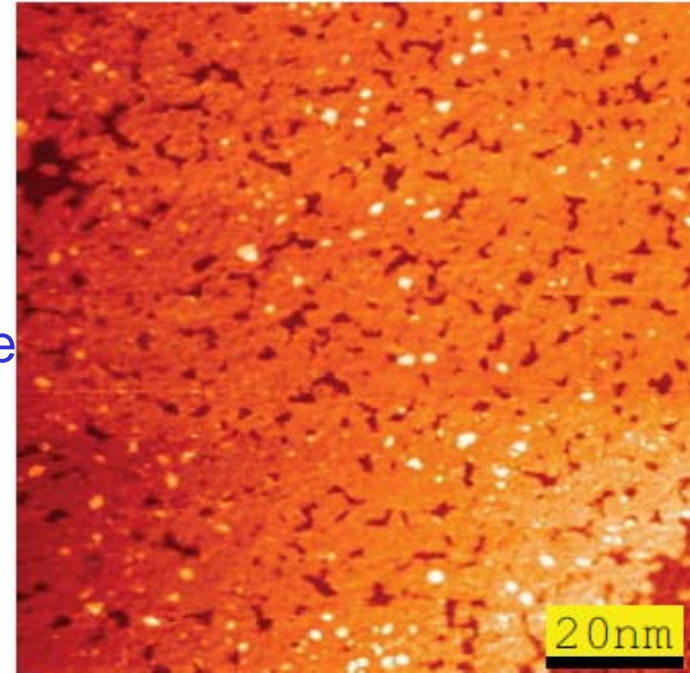


# Ultrathin Co on graphene

## Pulsed-Laser Deposition

- Layer-by-layer  
growth up to 1.5nm

STM  
(thickness 0.8nm)  
Growth at  
room  
temperature

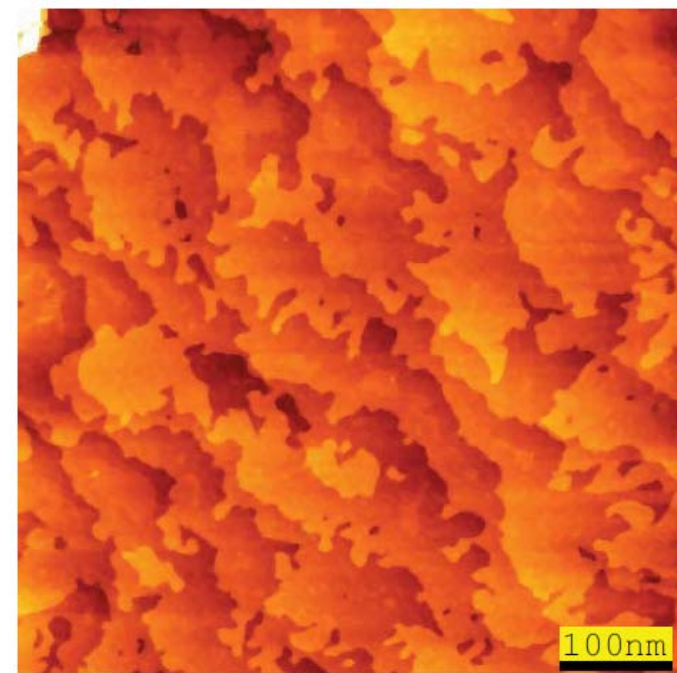
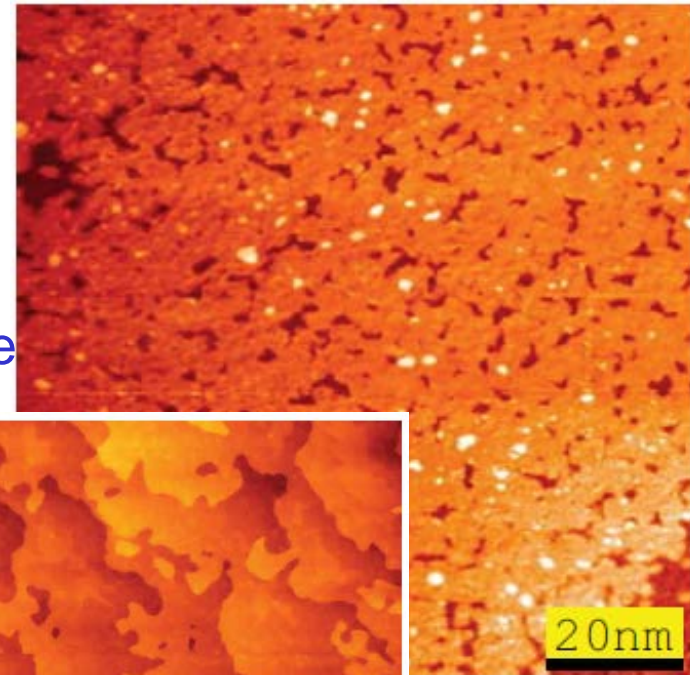


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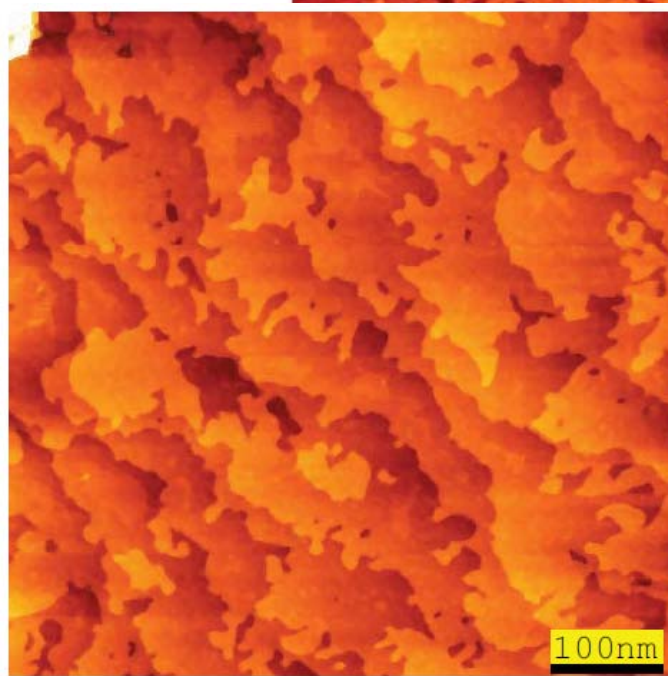
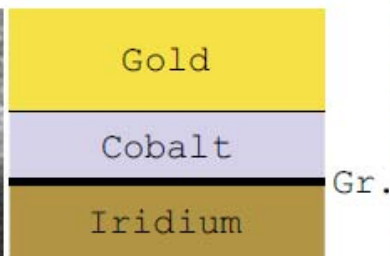
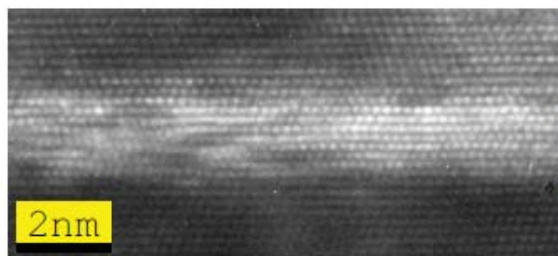
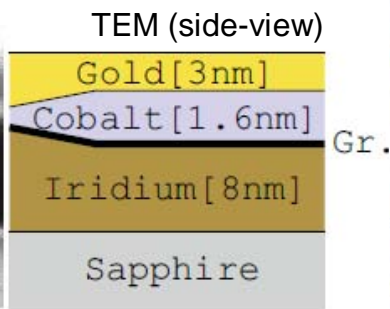
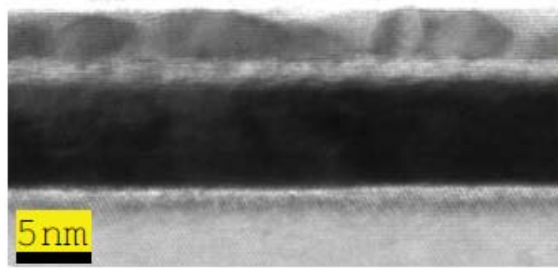
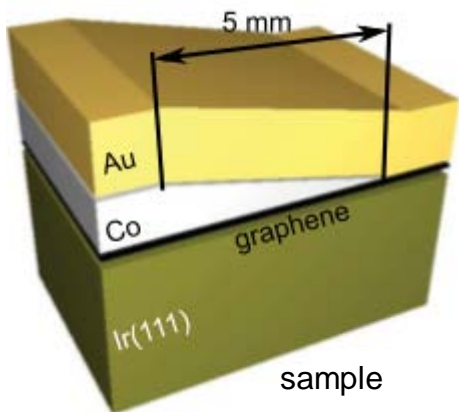
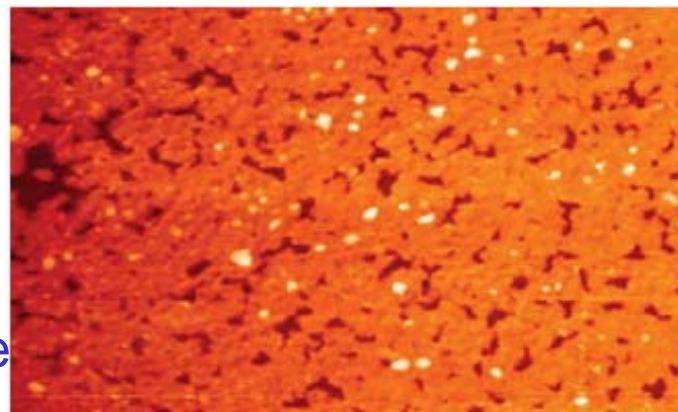
After  
annealing  
400°C  
STM  
(thickness 1.7nm)

# Ultrathin Co on graphene

## Pulsed-Laser Deposition

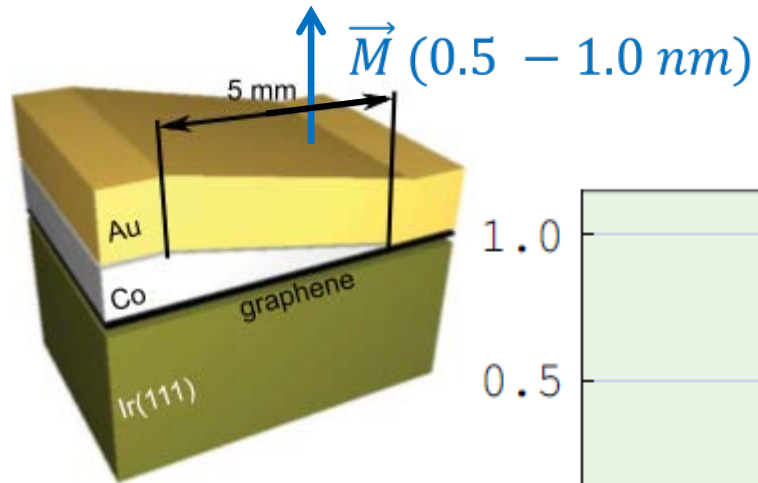
- Layer-by-layer growth up to 1.5nm
- Au-capping

STM  
(thickness 0.8nm)  
Growth at  
room  
temperature

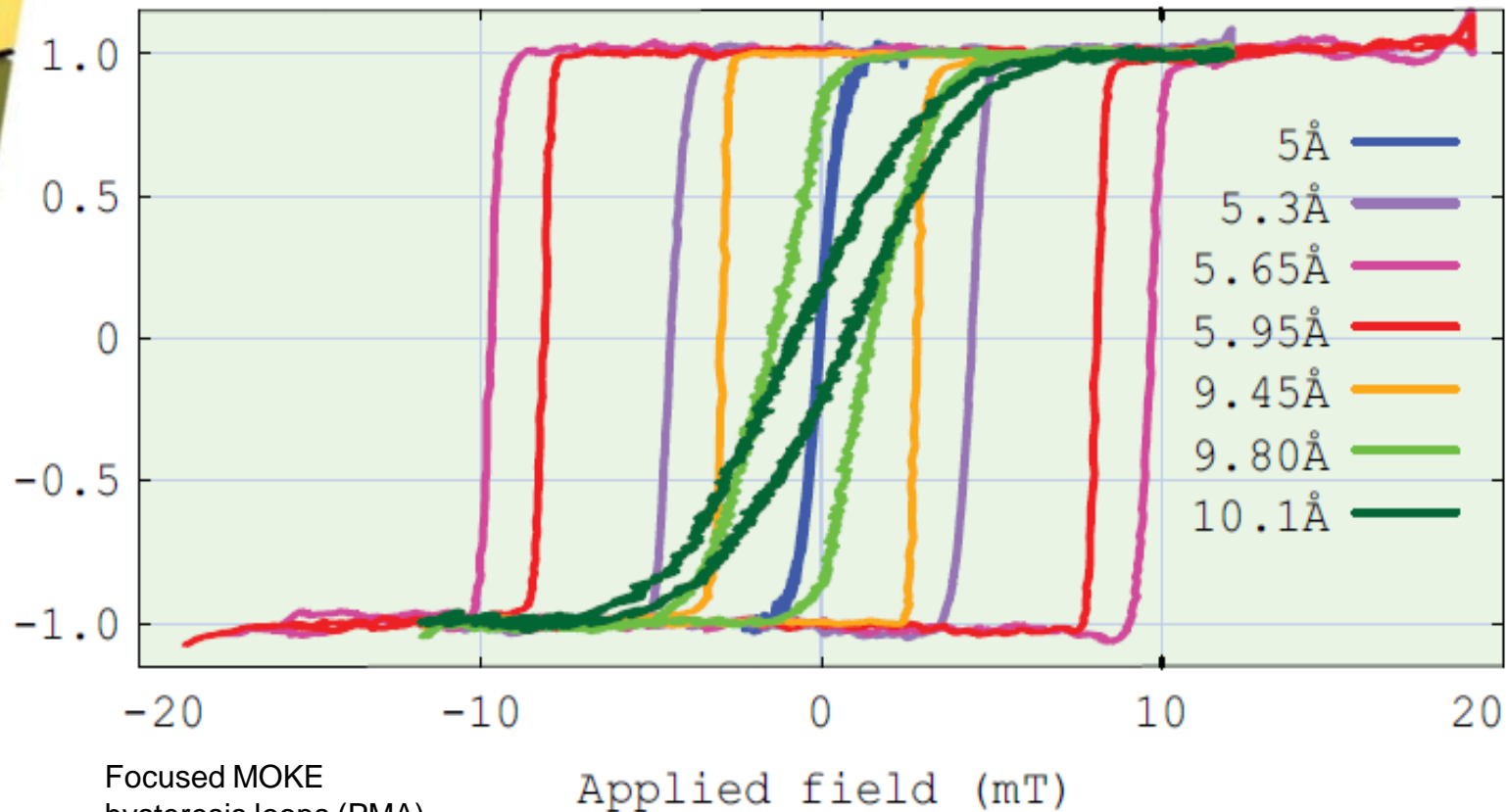


After  
annealing  
**400°C**  
STM  
(thickness 1.7nm)

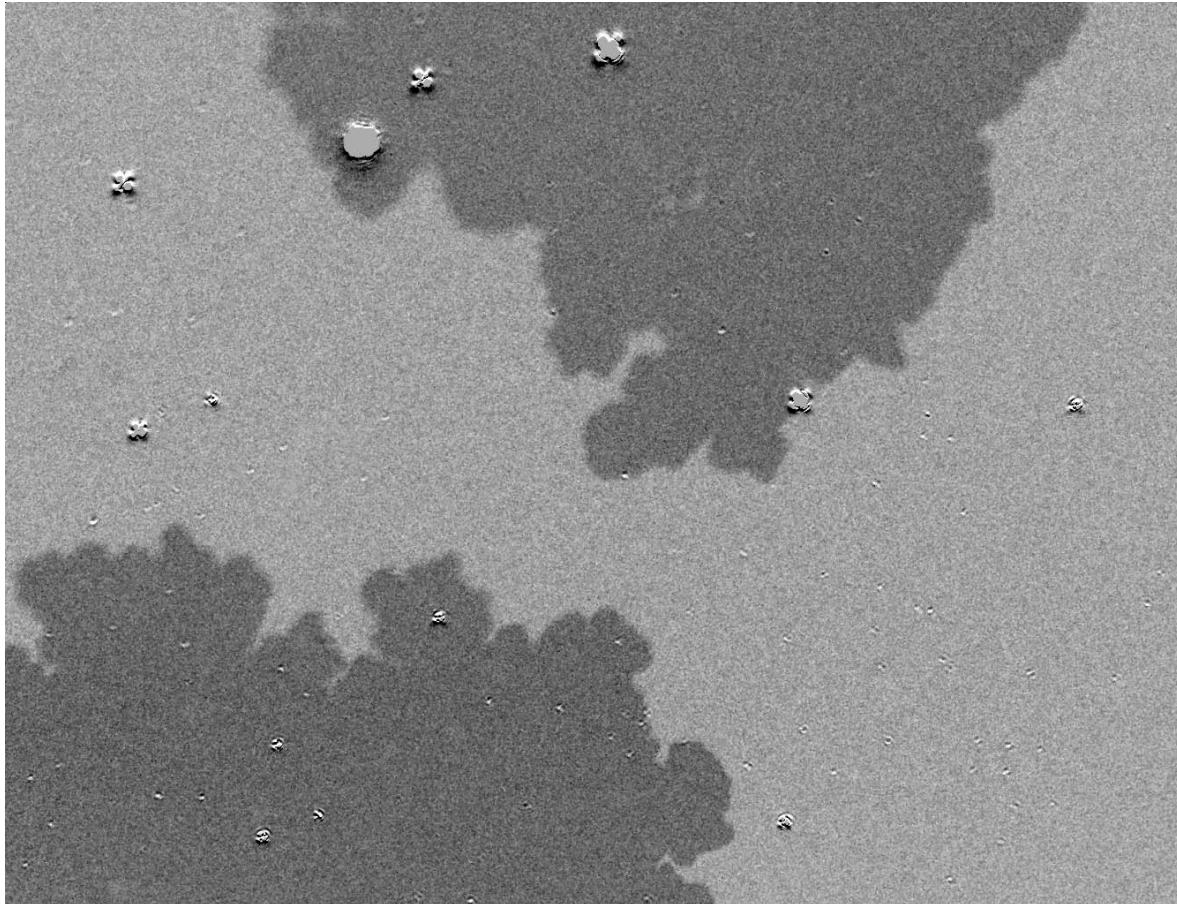
# Perpendicular magnetic anisotropy



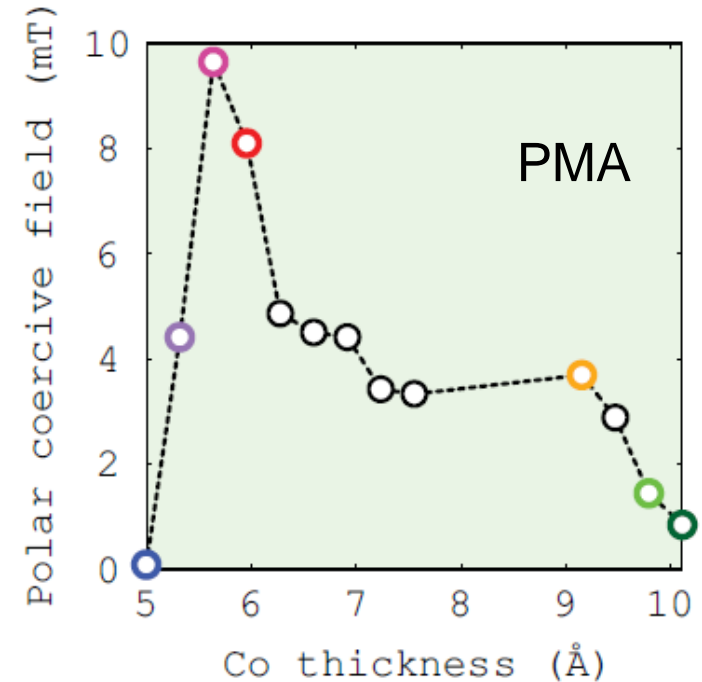
Reorientation transition seems abrupt



# Domain propagation



MOKE microcopy image  $130 \times 170 \mu\text{m}^2$ ,  $\perp$  field: 4mT, thickness: 0.8 nm

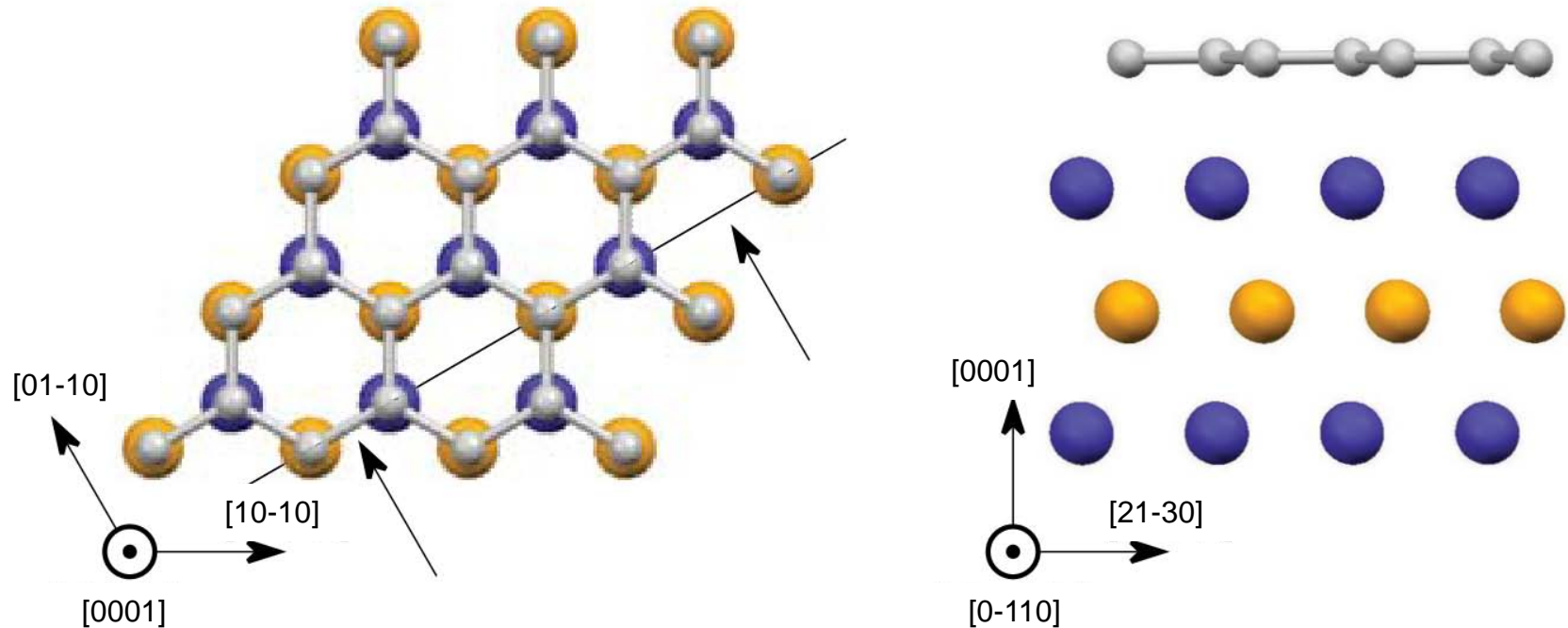


- Pd/Co/Pd, Au/Co/Au (111), Pt/Co/Pt(111)
- $\text{AlO}_x/\text{Co}/\text{Pt}(111)$

M. T. Johnson et al., Phys. Rev. Lett. **101**(2), 026803  
 B. Rodmacq et al., Phys. Rev. B **79**, 024423 (2009)

# Origin of PMA?

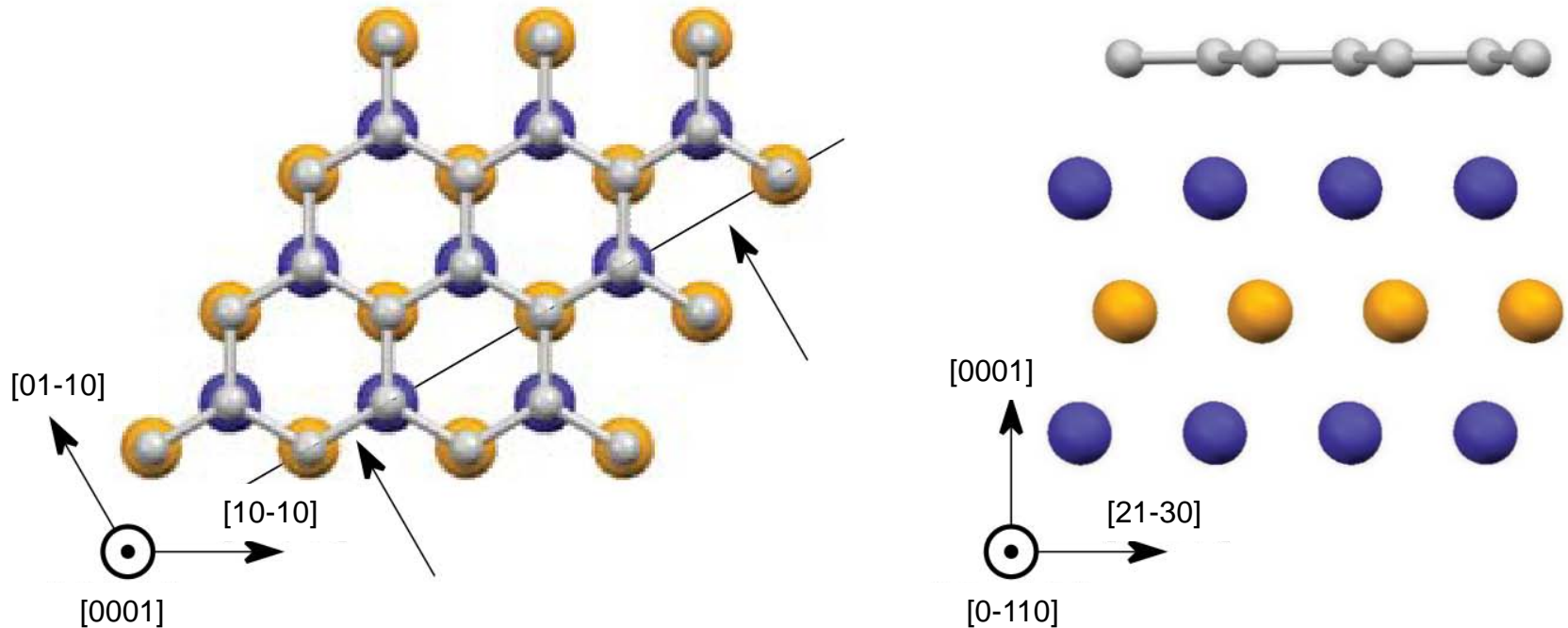
*Ab initio*, spin polarized calculation with spin-orbit coupling



in-plane magnetization?

# Origin of PMA?

*Ab initio*, spin polarized calculation with spin-orbit coupling

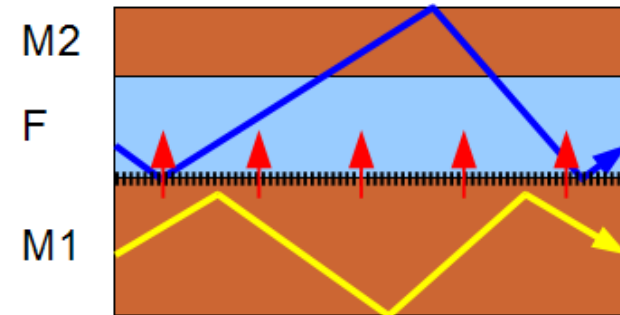
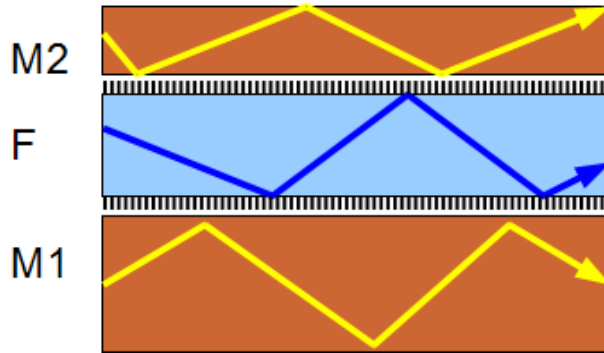


Graphene-Co:  $+0.8\text{mJ/m}^2$   
 Au-Co:  $+0.6\text{mJ/m}^2$

# Perspectives

Force parallel channels for conduction

Rashba-like effects for domain-wall motion

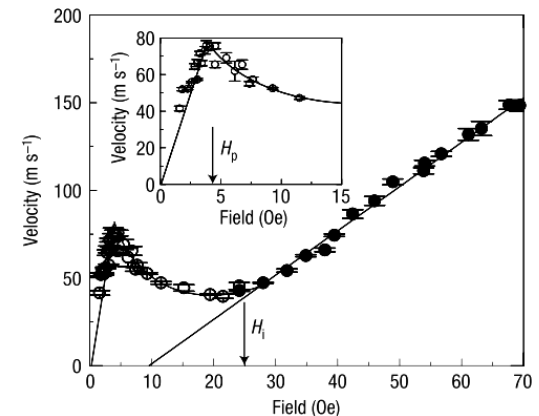
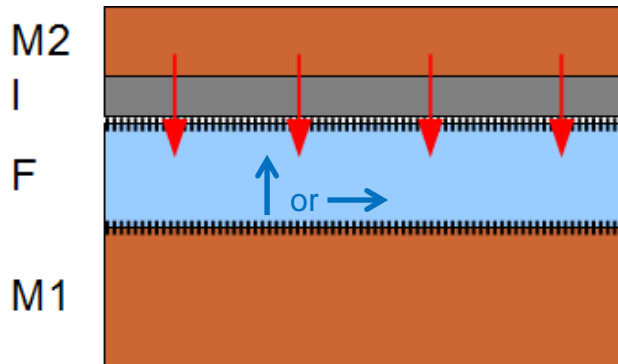


Keep a high polarization in Ferro (F)

I. M. Miron et al., Nature. Mater. **9**, 230 (2010)

Electric field control of magnetism

Domain wall motion below the Walker breakdown



M. Weisheit et al., Science **315**, 349 (2007)

Beach et al., Nature Mater. **4**, 741 (2005)

## Merci pour votre attention!

O. Fruchart, J. Coraux, J. Vogel, S. Pizzini, L. Ranno, C. Vo-Van,  
Z. Kassir-Bodon: Growth, Magnetic characterization, Hall  
conductance measurements

V. Santonacci, P. David: technical support

V. Salvador, P. Bayle-Guillemaud: TEM measurements

H. Yang, M. Chshiev: *ab initio* calculation